Working Towards Large Area, Picosecond-Level Photodetectors

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The LAPPD Collaboration

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Goals:
• Newly funded (end of August) by DOE and NSF
• 4 National Labs
• 5 Divisions at Argonne
• 3 US small companies;
• Electronics expertise at Universities of Chicago and Hawaii

• Exploit advances in material science and nanotechnology to develop new, batch methods for producing cheap, large area MCPs.
• To develop a commercializable product on a three year time scale.
Introduction: What If?

Large Water-Cherenkov Detectors will likely be a part of future long-baseline neutrino experiments.

What if we could build cheap, large-area MCP-PMTs:

• ~ 100 psec time resolution.
• ~ millimeter-level spatial resolution.
• With close to 100% coverage.
• Cost per unit area comparable to conventional PMTs.

How could that change the next-gen WC Detectors?

• Could these features improve background rejection?
• In particular, could more precision in timing information combined with better coverage improve analysis?
Timing in Water Cherenkov

A simple parametric model:
- Cherenkov cone with reasonable photon statistics
- Emanating from the center of a spherical WC detectors with different radii
- Includes models for absorption, scattering, chromatic dispersion

- Fit the leading edge of the arriving light with a Gaussian.
- The uncertainty on the position of the Gaussian approximates the uncertainty on the arrival time of the Cherenkov cone.
- This uncertainty depends on:
  - The rise time (chromatic dispersion)
  - Statistics (scattering, absorption, coverage, distance)

~2ns rise time

At large distances, the uncertainty on arrival time depends strongly on coverage.

J. Felde, B. Svoboda: UC-Davis
Timing in Water Cherenkov

Full GEANT MC study

- Cylindrical Geometry
- Tracks from 500 MeV Gammas
- Fit for tracks based on arrival time information
- How does this scale with time resolution?

Preliminary results show that useful information is contained in arrival time distributions.

- Potential for improved $\pi^0$ background suppression in two ways:
  - When $\pi^0$ decays to 2 back-to-back gammas: more coverage, could make it less likely to lose the second gamma
  - When both decay gammas are very forward: with TOF information, could be more likely to distinguish two separate tracks.

- Much more work to be done. Official LBNE WCh MC now available.

M. Wetstein (ANL/UofC), M. Sanchez (Iowa State/ANL), B. Svoboda (UC Davis)
Anatomy of an MCP-PMT

1. Photocathode
2. Multichannel Plates
3. Anode (stripline) structure
4. Vacuum Assembly
5. Front-End Electronics

Conversion of photons to electrons.
Anatomy of an MCP-PMT

1. Photocathode
2. Microchannel Plates
3. Anode (stripline) structure
4. Vacuum Assembly
5. Front-End Electronics

Amplification of signal. Consists of two plates with tiny pores, held at high potential difference. Initial electron collides with pore-walls producing an avalanche of secondary electrons. **Key to our effort.**
Anatomy of an MCP-PMT

1. Photocathode
2. Microchannel Plates
3. Anode (stripline) structure
4. Vacuum Assembly
5. Front-End Electronics

Charge collection. Brings signal out of vacuum.
Anatomy of an MCP-PMT

1. Photocathode
2. Microchannel Plates
3. Anode (stripline) structure
4. Vacuum Assembly
5. Front-End Electronics

Maintenance of vacuum. Provides mechanical structure and stability to the complete device.
Anatomy of an MCP-PMT

1. Photocathode
2. Microchannel Plates
3. Anode (stripline) structure
4. Vacuum Assembly
5. Front-end electronics

Acquisition and digitization of the signal.
Channel Plate Fabrication

Conventional MCP Fabrication

• Pore structure formed by drawing and slicing lead-glass fiber bundles. The glass also serves as the resistive material.
• Chemical etching and heating in hydrogen to improve secondary emissive properties.
• Expensive, requires long conditioning, and uses the same material for resistive and secondary emissive properties. (Problems with thermal run-away).

Proposed Approach

• Separate out the three functions
• Hand-pick materials to optimize performance.
• Use Atomic Layer Deposition (ALD): a cheap industrial batch method.
Atomic Layer Deposition

- A conformal, self-limiting process.
- Allows atomic level thickness control.
- Applicable for a large variety of materials.

**ALD Thin Film Materials**

- Oxide
- Nitride
- Phosphide/Arsenide
- Sulphide/Selenide/Telluride
- Carbide
- Fluoride
- Dopant
- Mixed Oxide

J. Elam, A. Mane, Q. Peng, T. Prolier (ANL:ESD/HEP), N. Sullivan (Arradiance), A. Tremsin (Arradiance, SSL)
Channel Plate Fabrication w/ ALD

1. Start with a porous, insulating substrate that has appropriate channel structure.

- borosilicate glass filters (default)
- Anodic Aluminum Oxide (AAO)

Incom

H. Wang (ANL), D. Routkevitch (Synkera)
Channel Plate Fabrication w/ ALD

1. Start with a porous, insulating substrate that has appropriate channel structure.

- borosilicate glass filters (default)
- Anodic Aluminum Oxide (AAO)

2. Apply a resistive coating (ALD)
Channel Plate Fabrication w/ ALD

1. Start with a porous, insulating substrate that has appropriate channel structure.

2. Apply a resistive coating (ALD)

3. Apply an emissive coating (ALD)

Alternative ALD Coatings:
- MgO
- ZnO
- Al₂O₃
- SiO₂ (ALD SiO₂ also)
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Channel Plate Fabrication w/ ALD

1. Start with a porous, insulating substrate that has appropriate channel structure.

   - borosilicate glass filters (default)
   - Anodic Aluminum Oxide (AAO)

2. Apply a resistive coating (ALD)
3. Apply an emissive coating (ALD)
4. Apply a conductive coating to the top and bottom (thermal evaporation or sputtering)

Alternative ALD Coatings:

- MgO
- ZnO
- Al₂O₃

Conventional MCP’s:
- SiO₂
Photocathode Fabrication

In parallel with conventional photo-cathode techniques, pursue more novel photocathode technologies.

- Nano-structured photocathodes:
  - Reduction of reflection losses (light trap)
  - Heterogeneous structure permits multi-functionality (electrically, optically, electron-emission, “ion-etching resistant”)
  - Increased band-gap engineering capabilities

- Pure-gas fabrication
  - Could possibly streamline manufacturing process and reduce costs

K. Attenkofer(APS), Z. Yusof(HEP)
S. Jelinsky, J. McPhate, O. Siegmund (SSL)
M. Pellin, T. Proslier(MSD)
Looking into sealed glass-panel technologies. Device construction must:

- Maintain 50Ω impedance through vacuum seal
- Avoid damage to photocathode during assembly
- Maintain integrity of channel plates, spacers
- Allow for vacuum tight sealing of outer “envelope” across uneven surfaces of varying composition
- Be able to handle high pressure and mechanical stress.

Working with various glass vendors and experts on these.

R. Northrop, H. Frisch, S. Asare (UC), M. Minot (Minotech Eng.), G. Sellberg (Fermilab), O. Siegmund (SSL), A. Tremsin (SSL/Arradiance), R. Barwhani (UCB), D. Walters (NE/ANL), R. Wagner (HEP/ANL),
Front End Electronics

- Collaboration between U of Chicago and Hawaii.
- Resolution depends on # photoelectrons, analog bandwidth, and signal-to-noise.
- Transmission Line: readout both ends → position and time
- Cover large areas with much reduced channel count.
- Simulations indicate that these transmission lines could be scalable to large detectors without severe degradation of resolution.

Wave-form sampling is best, and can be implemented in low-power widely available CMOS processes (e.g. IBM 8RF). Low cost per channel.

First chip submitted to MOSIS -- IBM 8RF (0.13 micron CMOS)- 4-channel prototype. Next chip will have self-triggering and phase-lock loop

Testing and Characterization

**Microscopic/Materials-Level**

**Material Science Division, ANL**
- Constructing dedicated setup for low-energy SEE and PE measurements of ALD materials/photocathodes.
- Parts-per-trillion capability for characterizing material composition.

**Berkeley SSL**
- Decades of experience.
- Wide array of equipment for testing individual and pairs of channel plates.
- Infrastructure to produce and characterize a variety of conventional photocathodes.

**Macroscopic/Device-Level**

**HEP Laser Test Stand, ANL**
- Fast, low-power laser, with fast scope.
- Built to characterize sealed tube detectors, and front-end electronics.
- Highly Automated

**Advanced Photon Source, ANL**
- Fast femto-second laser, variety of optical resources, and fast-electronics expertise.
- Study MCP-photocathode-stripline systems close to device-level. Timing characteristics amplification etc.
Simulation

• Working to develop a first-principles model to predict MCP behavior, at device-level, based on microscopic parameters.

• Will use these models to understand and optimize our MCP designs.

Transit Time Spread (TTS)

Comparison of TTS for direct and tilted channels

Z. Yusov, S. Antipov, Z. Insepov (ANL), V. Ivanov (Muons, Inc), A. Tremsin (SSL/Arradiance), N. Sullivan (Arradiance)
LAPPD Collaboration: Large Area Picosecond Photodetectors

Status After Several Several Months

- Using our electronic front-end and striplines with a commercial Photonis MCP-PMT, were able to achieve 1.95 psec differential resolution, 97 µm position resolution (158 photoelectrons).
- Demonstrated ability produce 33 mm ALD coated channel-plate samples.
- Development of advanced testing capabilities underway.
- Preliminary results at APS show amplification in a commercial MCP after ALD coating.
- Growing collaboration between simulation and testing groups.

Comparison of MCP Amplification Before and After ALD Coating

- After characterizing the Photonis MCP, we coat the plates with 10 nm Al₂O₃.
- The “after-ALD” measurements have been taken without scrubbing.
- These measurements are ongoing.
Summary of Potential Payoffs

- Improved $\pi^0$/electron separation.
  - Better vertex resolution.
  - Additional forward ring separation.
  - Lowered threshold for lower energy gamma detection.
- Reduced magnetic field susceptibility compared to PMTs.
- Increased fiducial volume by designing flat photodetectors.
- Lessened constraints on cavern height, thanks to geometric design.

Effort is under way to study each of these possibilities.
Conclusions

• Funding arrived in August and we’re on a 3 year time table. Lots of work ahead. Preliminary achievements are encouraging.

• May make photo-detection significantly cheaper.
  • Reduce bottom-line manufacturing costs.
  • Economic impacts of new vendor/alternative in the market.

• If successful, this project presents potential opportunities for future Water Cherenkov Detectors.
  • New set of optimizations for analysis using better spatial and timing resolution.
  • Variations in overall detector design.
  • Direct analysis-driven feedback to guide photodetector design.
  • Lessen the neutrino-community’s dependence on a single vendor.
  • Will require detailed simulations.
Thanks

- NNN09 for hosting.
- LAPPD collaboration for their help and hard work.
- Mayly Sanchez, Henry Frisch, Bob Svoboda for their feedback and guidance.
How Would This Affect the LBNE Time-Table?

• This project is on a 3 year time-table. We have no intention or expectation for LBNE waiting for us.
  - We’re not likely to be ready for the first detector.
  - Could be ready for upgrades or a second detector.

• LBNE is not the only application we’re interested in:
  - Collider physics: time-of-flight to determine flavor.
  - Medical PET imaging
  - Homeland security
How Much Would These Cost?
Too soon to tell…

But, keeping cost down is a major objective:
• Made from inexpensive materials.
• Use industrial batch processes.
• Inexpensive electronics, trying to reduce number of necessary readout channels.

In addition to the bottom-line cost of the detectors are secondary effects.
• Market impact.
• Possible savings on civil construction. Detector can be built closer to walls.

Cost/unit area is not the only relevant factor. Physics gains could be worth a little more.
What About Chromatic Dispersion?

• Better coverage (more photon statistics) could recover some of the precision loss due to dispersion.
• Even if chromatic dispersion is prohibitive at large distances, timing might be useful for events closer to the detector wall.
• With close to 100% coverage, we could perhaps afford to sacrifice statistics
  • To look at a narrower range of wavelengths
  • To look in a region with less wavelength dependence.
• There are many new degrees of freedom to think about.
What About Chromatic Dispersion?

- We haven’t *had* to think about timing on the sub-nanosecond scale.
- This is a new opportunity. There is room for creative analysis.